

Ethics and Technology: New Challenges for the 21st Century Practitioner

Event

Aug 13, 2013

PLI New York Center
810 Seventh Avenue at 53rd Street
21st floor
New York, NY 10019

Hinshaw & Culbertson LLP partner David A. Lewis will serve as the Chairperson for the panel discussion “Ethics and Technology: New Challenges for the 21st Century Practitioner,” at the Practising Law Institute (PLI) Seminar on August 13, 2013, from 12:00 p.m. to 2:10 p.m. (ET).

Using the latest technology to communicate with clients, the court, and the public is often a necessary part of a lawyer’s job. Using these tools properly is critical particularly when it involves the risk of an inadvertent disclosure of client confidential information. The stakes are raised even higher when relying on an Internet that does not fit within our traditional notions of jurisdictional limitations. The next generation of Internet communications (e.g., blogs and social networks) carry with them even greater risks, along with their benefits. At this program, you will learn about the potential ethical risks arising from use of technology and practical solutions to these issues.

You will learn about ethical issues arising from:

- Confidentiality obligations under the Rules of Professional Conduct
- Data protection in the digital world (the cloud and beyond...)
- Technology in legal practice, data devices and other technologies
- The inadvertent disclosure dilemma
- Use of social media

For more information or to register for this event, please visit the [PLI](http://www.pli.com) website.

Hinshaw & Culbertson LLP is a U.S.-based law firm with offices nationwide. The firm's national reputation spans the insurance industry, the financial services sector, professional services, and other highly regulated industries. Hinshaw provides holistic legal solutions—from litigation and dispute resolution, and business advisory and transactional services, to regulatory compliance—for clients of all sizes. Visit www.hinshawlaw.com for more information and follow @Hinshaw on LinkedIn and X.